

TL/G/10034-4

**DESCRIPTION**

Process 06 is a monolithic, double-diffused, silicon epitaxial Darlington.

**APPLICATION**

This device is designed for applications requiring extremely high current gain at collector currents up to 1.5A and high breakdown voltage.

**PRINCIPLE DEVICE TYPES**

**TO-202 EBC:** NSDU45A

**TO-226 EBC:** 2N7053

**TO-237 EBC:** 92PU45A

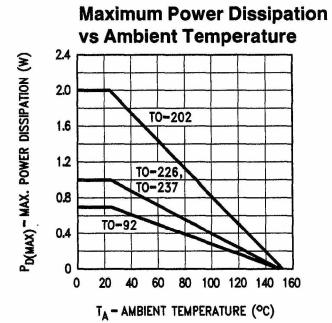
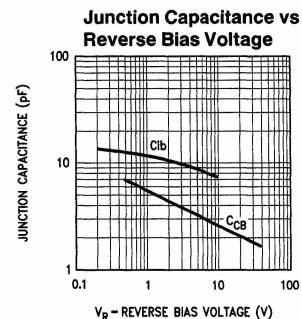
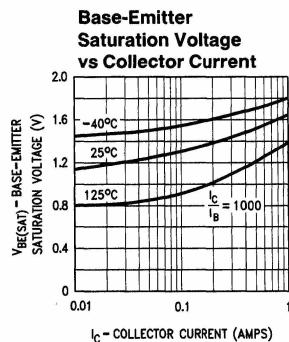
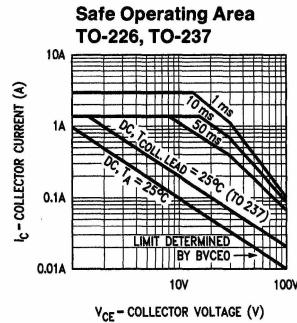
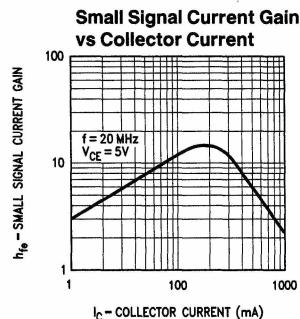
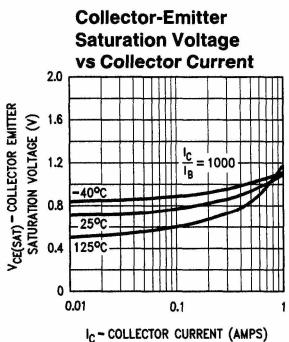
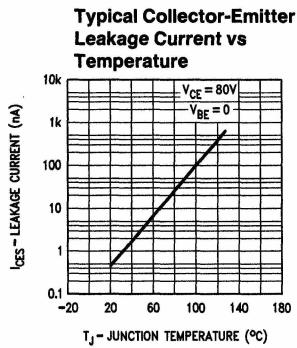
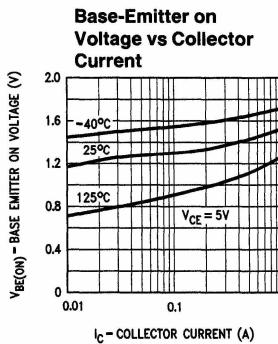
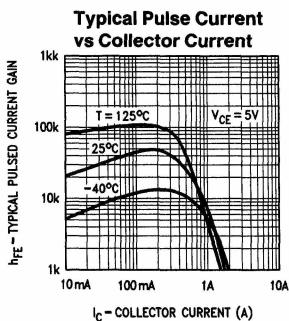
**TO-92 EBC:** 2N7052

**TO-92 ECB:** 2N7051

**ELECTRICAL CHARACTERISTICS ( $T_A = 25^\circ\text{C}$ )**

Symbol	Conditions	Min	Typ	Max	Units
$BV_{CEO}$	$I_C = 1 \text{ mA}, I_B = 0$	100			V
$BV_{EBO}$	$I_E = 1 \text{ mA}, I_C = 0$	12			V
$I_{CBO}$	$V_{CB} = 80\text{V}, I_E = 0$			100	nA
$I_{CES}$	$V_{CE} = 80\text{V}, V_{BE} = 0$			100	nA
$I_{EBO}$	$V_{EB} = 7\text{V}$			100	nA
$h_{FE}$	$I_C = 10 \text{ mA}, V_{CE} = 5\text{V}$ $I_C = 100 \text{ mA}, V_{CE} = 5\text{V}$ $I_C = 1 \text{ A}, V_{CE} = 5\text{V}$	1,000 10,000 500	40,000	20,000 200,000	
$V_{CE(s)}$	$I_C = 100 \text{ mA}, I_B = 0.1 \text{ mA}$		0.75	1.1	V
$V_{BE(s)}$	$I_C = 100 \text{ mA}, I_B = 0.1 \text{ mA}$		1.3	1.5	V
$C_{cb}$	$V_{CB} = 10\text{V}, I_E = 0, f = 1 \text{ MHz}$		3	6	pF
$C_{ib}$	$V_{EB} = 0.5\text{V}, I_E = 0, f = 1 \text{ MHz}$		14	20	pF
$h_{fe}$	$I_C = 100 \text{ mA}, V_{CE} = 5\text{V}, f = 20 \text{ MHz}$		8		
$P_{D(\max)}$ TO-202	$T_C = 25^\circ\text{C}$ $T_A = 25^\circ\text{C}$	12			W
TO-226	$T_A = 25^\circ\text{C}$	2			W
TO-237	$T_C = 25^\circ\text{C}$ $T_A = 25^\circ\text{C}$	1			W
TO-92	$T_A = 25^\circ\text{C}$	2			W
TO-92	$T_A = 25^\circ\text{C}$	850			mW
TO-92	$T_A = 25^\circ\text{C}$	700			mW
$T_{J(\max)}$	All Plastic Parts	150			°C

# Process 06



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